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Substitute for form 1449A-PTO

INFORMATION DISCLOSURE
STATEMENT BY APPLICANT

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Sheet 1 Of 8

COMPLETE IF KNOWN

Application Number	10/026,019
Filing Date	December 27, 2001
First Named Inventor	Ralph Johnson
Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

U.S. PATENT DOCUMENTS

Examiner Initials ¹	Cite No ¹	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (if known)			
DW		US 4445218		04-24-1984	Coldren	
		US 4608697		08-26-1986	Coldren	
		US 4622672		11-11-1986	Coldren et al.	
		US 4829347		05-09-1989	Cheng et al.	
		US 4873696		10-10-1989	Coldren et al.	
		US 4896325		01-23-1990	Coldren	
		US 5045499		09-03-1991	Nishizawa et al.	
		US 5082799	A	01-21-1992	Holmstrom et al.	
		US 5245622	A	09-14-1993	Jewell et al.	
		US 5251225	A	10-05-1993	Eglash et al.	
		US 5293392	A	03-08-1994	Shieh et al.	
		US 5343487	A	08-30-1994	Scott et al.	
		US 5358880	A	10-25-1994	Lebby et al.	
		US 5365540	A	11-15-1994	Yamanaka	
		US 5392307	A	02-21-1995	Sugiyama et al.	
		US 5416044	A	05-16-1995	Chino et al.	
		US 5422901	A	06-06-1995	Lebby et al.	
		US 5468343	A	11-21-1995	Kitano	
		US 5491710	A	02-13-1996	Lo	
		US 5513204	A	04-30-1996	Jayaraman	
		US 5568504	A	10-22-1996	Kock et al.	
		US 5588995	A	12-31-1996	Sheldon	
		US 5631472	A	05-20-1997	Cunningham et al.	
		US 5693180	A	12-02-1997	Furukawa et al.	
		US 5719891	A	02-17-1998	Jewell	
		US 5719894	A	02-17-1998	Jewell et al.	

Examiner Signature

Date Considered

04/04/04

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Sheet 2 Of 8

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First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

DW	US 5719895	A	02-17-1998	Jewell et al.	
	US 5729567	A	03-17-1998	Nakagawa	
	US 5732103	A	03-24-1998	Ramdani et al.	
	US 5747366	A	05-05-1998	Brillouet et al.	
	US 5754578	A	05-19-1998	Jayaraman	
	US 5757833	A	05-26-1998	Arakawa et al.	
	US 5805624	A	09-08-1998	Yang et al.	
	US 5809051	A	09-15-1998	Oudar	
	US 5815524	A	09-29-1998	Ramdani et al.	
	US 5818862	A	10-06-1998	Salet	
	US 5825796	A	10-20-1998	Jewell et al.	
	US 5835521	A	11-10-1998	Ramdani et al.	
	US 5877038	A	03-02-1999	Coldren et al.	
	US 5883912	A	03-16-1999	Ramdani et al.	
	US 5898722	A	04-27-1999	Ramdani et al.	
	US 5903586	A	05-11-1999	Ramdani et al.	
	US 5912913	A	06-15-1999	Kondow et al.	
	US 5943357	A	08-24-1999	Lebby et al.	
	US 5943359	A	08-24-1999	Ramdani et al.	
	US 5956363	A	09-21-1999	Lebby et al.	
	US 5960018	A	09-28-1999	Jewell et al.	
	US 5974073	A	10-26-1999	Canard et al.	
	US 5978398	A	11-02-1999	Ramdani et al.	
	US 5985683	A	11-16-1999	Jewell	
	US 5991326	A	11-23-1999	Yuen et al.	
	US 6021147	A	02-01-2000	Jiang et al.	
	US 6046065	A	04-04-2000	Goldstein et al.	
	US 6049556	A	04-11-2000	Sato	
	US 6052398	A	04-18-2000	Brillouet et al.	
	US 6057560	A	05-02-2000	Uchida	
	US 6061380	A	05-09-2000	Jiang et al.	
✓	US 6061381	A	05-09-2000	Adams et al.	

Examiner Signature		Date Considered	04/04/04
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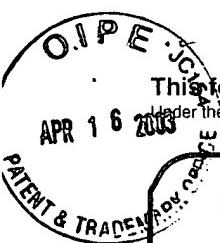
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Sheet 3 Of 8

COMPLETE IF KNOWN

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Filing Date	December 27, 2001
First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

US 6121068	A	09-19-2000	Ramdani et al.
US 6127200	A	10-03-2000	Ohiso et al.
US 6148016	A	11-14-2000	Hegblom et al.
US 6195485	B1	02-27-2001	Coldren et al.
US 6207973	B1	03-27-2001	Sato et al.
US 6252896	B1	06-26-2001	Tan et al.
US 6314118	B1	11-06-2001	Jayaraman et al.
US 6341137	B1	01-22-2002	Jayaraman et al.
US 6359920	B1	03-19-2002	Jewell et al.
US 6362069	B1	03-26-2002	Forrest et al.
US 6366597	B1	04-02-2002	Yuen et al.
US 6372533	B2	04-16-2002	Jayaraman et al.
US 6424669	B1	07-23-2002	Jiang et al.
US 6434180	B1	08-13-2002	Cunningham
US 6542530	B1	04-01-2003	Shieh et al.
US 2002/0067748	A1	06-06-2002	Coldren et al.
US 2002/0071464	A1	06-13-2002	Coldren et al.
US 2002/0075920	A1	06-20-2002	Spruytte et al.
US 2002/0071471	A1	06-13-2002	Kim et al.
US 2002/0075929	A1	06-20-2002	Cunningham
US 2002/0090016	A1	07-11-2002	Coldren et al.
US 2002/0131462	A1	09-19-2002	Line et al.
US 2003/0053510	A1	03-20-2003	Yuen et al.

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Sheet 4 of 8

COMPLETE IF KNOWN

Application Number	10/026,019
Filing Date	December 27, 2001
First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No ¹	Foreign Patent Document			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ⁶
		Country Code ³	Number ⁴	Kind Code ⁵ (if known)				
DW		EP	0 740 377	A1	10-30-1996	Hewlett-Packard Company		
		EP	0 740 377	B	10-30-1996	Hewlett-Packard Company		
		EP	0 765 014	A1	03-26-1997	France Telecom		
		EP	0 765 014	B1	07-28-1999	France Telecom		
		EP	0 822 630	A1	02-04-1998	Hewlett-Packard Company		
		EP	0 874 428	A2	10-28-1998	Motorola, Inc.		
		EP	0 874 428	A3	11-04-1998	Motorola, Inc.		
		EP	0 874 428	B1	15-04-1998	Motorola, Inc.		
		EP	1 294 063	A1	03-19-2003	Avalong Photonics AG		
		JP	57026492	A	02-12-1982	NEC Corp.		
		WO	98/007218	A1	02-19-1998	W.L. Gore & Associates, Inc.		
		WO	00/033433	A2	06-08-2000	Arizona Board of Regents		
		WO	00/033433	A3	06-08-2000	Arizona Board of Regents		
		WO	00/038287	A1	06-29-2000	Honeywell, Inc.		
		WO	00/052789	A2	02-29-2000	The Regents of the University of California		
		WO	00/052789	A3	02-29-2000	The Regents of the University of California		
		WO	00/065700	A2	11-02-2000	Gore Enterprise Holdings, Inc.		
		WO	00/065700	A3	11-02-2000	Gore Enterprise Holdings, Inc.		
		WO	01/016642	A2	03-08-2001	Agility Communications		
		WO	01/016642	A3	03-08-2001	Agility Communications		
		WO	01/017076	A2	03-08-2001	The Regents of the University of California		
		WO	01/017076	A3	03-08-2001	The Regents of the University of California		

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Sheet 5 Of 8

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Filing Date	December 27, 2001
First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

DW	WO 01/018919 A1	03-15-2001	The Regents of the University of California	
	WO 01/024328 A2	04-05-2001	Agility Communications	
	WO 01/024328 A3	04-05-2001	Agility Communications	
	WO 01/033677 A2	05-10-2001	Arizona Board of Regents	
	WO 01/033677 A3	05-10-2001	Arizona Board of Regents	
	WO 01/084682 A2	11-08-2001	Agility Communications, Inc.	
	WO 01/093387 A2	12-06-2001	Sandia Corporation	
	WO 01/093387 A3	12-06-2001	Sandia Corporation	
	WO 01/095444 A2	12-13-2001	Agility Communications, Inc.	
	WO 01/098756 A2	12-27-2001	The Regents of the University of California	
	WO 02/003515 A2	01-10-2002	Agility Communications, Inc.	
✓	WO 02/017445 A1	02-28-2002	The Regents of the University of California	
✓	WO 02/084829 A1	10-24-2002	Cielo Communications, Inc.	

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T ²
DW		ALMUNEAU, G., et al., "Accurate control of Sb composition in AlGaAsSb alloys on InP substrates by molecular beam epitaxy", article, Journal of Crystal Growth, Vol 208, 05-06-1999, pgs 113-6.	
		ALMUNEAU, G., et al., "Improved electrical and thermal properties of InP-AlGaAsSb Bragg mirrors for long-wavelength vertical-cavity lasers", article, IEEE Photonics Technology Letters, Vol. 12, No 10, Oct 2000, pgs 1322-4,	
		ALMUNEAU, G., et al., "Molecular beam epitaxial growth of monolithic 1.55 μm vertical cavity surface emitting lasers with AlGaAsSb/AlAsSb Bragg mirrors", article, Journal of Vacuum Science Technology, Vol 8, No 3, May/Jun 2000, pgs 1601-4.	
		BLACK, K., et al. "Double-fused 1.5 μm vertical cavity lasers with record high T _c of 132K at room temperature", article, Electronics Letters, Vol 34, No 20, 10-01-1998, pgs 1947-9.	
		BLUM, O., et al., "Electrical and optical characteristics of AlAsSb/BaAsSb distributed Bragg reflectors for surface emitting lasers", article, Applied Physics Letters, Vol 67, No 22, 11-27-1995, pgs 3233-5.	
		BLUM, O., et al., "Highly reflective, long wavelength AlAsSb/GaAsSb distributed Bragg reflector grown by molecular beam epitaxy on InP substrates", article, Applied Physics Letters, Vo. 66, No 3, 01-16-1995, pgs 329-31.	
✓		BOUCART, J., et al., "1mW CW-RT monolithic VCSEL at 1.55 μm", article, IEEE Photonic Technology Letters, Vol 11, No 6, Jun 1999, pgs 629-31	

Examiner Signature

Date Considered

02/04/04

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First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

DW	CAMPBELL, J., et al., "Quantum dot resonant cavity photodiode with operation near 1.3 μm wavelength", article, Electronics Letters, Vol 33, No 15, 07-17-1997, pgs 1337-9.
	CHANG, C., et al., "Parasitics and design considerations on oxide-implant VCSELs", article, IEEE Photonics Technology Letters, Vol 13, No 12, Dec 2001, pgs 1274-6.
	CHOQUETTE, K., et al., "Room temperature continuous wave InGaAsN quantum well vertical-cavity lasers emitting at 1.3 μm", article, Electronics Letters, Vol 36, No. 16, 08-03-2000, pgs 1388-90.
	DOWD, P., et al., "Long wavelength (1.3 and 1.5 μm) photoluminescence from InGaAs/GaPAsSb quantum wells grown on GaAs", article, Applied Physics Letters, Vol 75, No 9, 08-30-1999, pgs 1267-9.
	DUDLEY, J., et al., "Water fused long wavelength vertical cavity lasers", conference proceedings, LEOS '93 Conference Proceedings, IEEE Lasers and Electro-Optics Society 1993 Annual Meeting, Nov 15/8, 1993, pgs 560-1.
	GOURLEY, F., et al., "Epitaxial semiconductor optical interference devices", invited paper, SPIE, Vol 792, 1987, pgs 178-189.
	GUDEN, M., et al., "Material parameters of quaternary III-V semiconductors for multiplayer mirrors at 1.55 μm wavelength", article, Modeling Simulation Material Science Engineering, Vol 4 1966, pgs 349-57.
	GUO, C., et al., "Theoretical investigation of strained InGaAs/GaPAsSb type-II quantum wells on GaAs for long wavelength (1.3 μm) optoelectronic devices", post-conference paper, Dept of Electrical Engineering & Center for Solid State Electronics Research, ASU, Tempe, AZ, Apr 1999, pgs 30-1.
	GUY, D., et al., "Theory of an electro-optic modulator based on quantum wells in a semiconductor étalon", conference paper, Quantum Well and Superlattice Physics, Mar 23/4, 1987, pgs 189-96.
	HALL, E., et al., "Electrically-pumped, single-epitaxial VCSELs at 1.55 μm with Sb-based mirrors", article, Electronics Letters, Vol 35, No 16, 08-05-1999, pgs 1-2.
	HALL, E., et al., "Increased lateral oxidation rates of AlInAs on InP using short-period superlattices", article, Applied Physics Letters, Vol 29, No 9, 01-08-2002, pgs 1100-4.
	HALL, E., et al., "Selectively etched undercut apertures in AlAsSb-based VCSELs", article, IEEE Photonics Technology Letters, Vol 13, No 2, Feb 2001, pgs 97-9.
	HEGBLOM, E., et al., "Small efficient vertical cavity lasers with tapered oxide apertures", article, Electronics Letters, Vol 34, No 9, 04-30-1998, pgs 895-6.
	HEROUX, J., et al., "Optical investigation of InGaAsN/GaAs strained multi-quantum wells", 20 th North American Conference on Molecular Beam Epitaxy, Oct 1-3, 2001, pg 2.
	HONG, Y., et al., "Improving Ga(In)NAs properties by migration-enhanced epitaxy and superlattices", 43 rd 2001 Electronic Material Conference, Session G, Paper G10, 06-27-2001.
	HONG, Y., et al., "Growth of GaInNAs quaternaries using a digital allow technique", conference paper, Journal of Vacuum Science and Technology B: Microelectronics and Nanometer Structures, Oct 01/3, 2001, pgs 1163-6.
	HUFFAKER, D., et al., "1.15 μm wavelength oxide-confined quantum-dot vertical-cavity surface-emitting laser", article, IEEE Photonics Technology Letters, Vol 10, No 2, Feb 1998, pgs 185-7.
	HUFFAKER, D., et al., "1.3 μm room-temperature GaAs-based quantum-dot laser", Applied Physics Letters, Vol 73, No 18, 11-02-1998, pgs 2564-6.
	IGA, K., "Semiconductor laser in the 21 st century", California conference papers, Photodetectors: Materials and Devices VI, Jan 22/4, 2001, pgs xi-xxv.
	JAYARAMAN, V., et al., "Uniform threshold current, continuous-wave, singlemode 1300 nm vertical cavity lasers from 0 to 70°C", article, Electronics Letters, Vol 34, No 14, 07-09-1998, pgs 1405-7.

Examiner
SignatureDate
Considered

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Attorney Docket Number	V637-02674 US

<input checked="" type="checkbox"/>	KIM, J., et al., "Epitaxially-stacked multiple-active-region 1.55 μm lasers for increased differential efficiency", article, Applied Physics Letters, Vol 74, No 22, 05-31-1999, pgs 3251-3.
<input type="checkbox"/>	KIM, J., et al., "Room-temperature, electrically-pumped multiple-active-region VCSELs with high differential efficiency at 1.55 μm", article, Electronics Letters, Vol 35, No 13, 06-24-1999, pgs 1-2.
<input type="checkbox"/>	KOTAKI, Y., et al., "GaInAsP/InP surface emitting layer with two active layers", article, Extended Abstracts of the 16 th (1984 International) conference on Solid State Devices and Materials, pgs 133-6.
<input type="checkbox"/>	KOYAMA, F., et al., "Room temperature CWS operation of GaAs vertical cavity surface emitting laser", article, The Transactions of the IEICE, Vol E71, No 11, Nov 1988, pgs 1089-90.
<input type="checkbox"/>	LARSON, J., et al., "GaInNAs-GaAs long-wavelength vertical-cavity surface-emitting laser diodes", article, IEEE Photonics Technology Letters, Vol 10, No 2, Feb 1998, pgs 188-90.
<input type="checkbox"/>	LEE, Y., et al., "Physics and nonlinear device applications of bulk and multiple quantum well GaAs", invited paper, SPIE Vol 792 Quantum Well and Superlattice Physics (1987), pgs 128-133.
<input type="checkbox"/>	LI, J., et al., "Persistent photoconductivity in Ga _{1-x} In _x N _y As _{1-y} ", article, Applied Physics Letters, Vol 75, No 13, 09-27-1999, pgs 1899-1901.
<input type="checkbox"/>	MIRIN, R., et al., "1.3 μm photoluminescence from InGaAs quantum dots on GaAs", article, Applied Physics Letter 67 (25), 12-18-1995, pgs 3795-7.
<input type="checkbox"/>	NAKAGAWA, S., et al., "1.55 μm InP-lattice-matched VCSELs with AlGaAsSb-AlAsSb DBRs", article, IEEE Journal on Selected Topics in Quantum Electronics, Vol 7, No 2, Mar/Apr 2001, pgs 224-30.
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<input type="checkbox"/>	NELSON, D., et al., "Band nonparabolicity effects in semiconductor quantum wells", article, Rapid Communications, Vol 35, No 17, 02-15-1987, pgs 7770-7773.
<input type="checkbox"/>	OHNOKI, N., et al., "Superlattice AlAs/AlInAs-oxide current aperture for long wavelength InP-based vertical-cavity surface-emitting laser structure", article, Applied Physics Letters, Vol 73, No 22, 11-30-1998, pgs 3262-4.
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<input type="checkbox"/>	PETERS, M., et al., "Band-gap engineered digital alloy interfaces for lower resistance vertical-cavity surface-emitting lasers", article, Applied Physics Letters, Vol 63, No. 25, Dec 1993, pgs 3411-3.
<input type="checkbox"/>	PIPREK, J., et al., "Thermal comparison of long-wavelength vertical-cavity surface-emitting laser diodes", Electronics Letters, 05-26-1994, Vol 30, No 11, pgs 866-868.
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<input type="checkbox"/>	RAJA, M., et al., "Novel wavelength-resonant optoelectronic structure and its application to surface-emitting semiconductor lasers", article, Electronics Letters, 09-01-1988, Vol 24, No 18, pgs 1140-1142.
<input checked="" type="checkbox"/>	SCOTT, J., et al., "High efficiency submilliamp vertical cavity lasers with intracavity contacts", article, IEEE Photonics Technology Letters, Vol 6, No 6, Jun 1994, pgs 678-80.

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Date Considered

02/04/04

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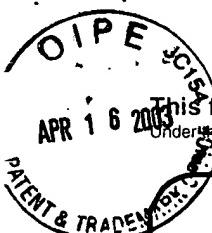
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STATEMENT BY APPLICANT

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Sheet 8 Of 8

COMPLETE IF KNOWN

Application Number	10/026,019
Filing Date	December 27, 2001
First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

W	SEKIGUCHI, S., et al., "Long wavelength GaInAsP/InP laser with n-n contacts using AlAs/InP hole injecting tunnel junction", article, Japanese Journal of Applied Physics, Part 2, No 4B, 04-15-1999, pgs L443-5.
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Examiner Signature		Date Considered	04/04/04
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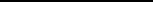
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COMPLETE IF KNOWN	
Application Number	10/026,019
Filing Date	December 20, 2001
First Named Inventor	Ralph Johnson
Group Art Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-02674 US

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COMPLETE IF KNOWN	
Application Number	10/026,019
Filing Date	December 20, 2001
First Named Inventor	Ralph Johnson
Att Unit	2828
Examiner Name	Tuan M Nguyen
Attorney Docket Number	V637-002674 US

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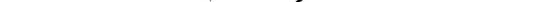
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		Filing Date	December 20, 2001
		First Name Inventor	Ralph Johnson
		Art Unit	2828
		Examiner Name	Tuan M Nguyen
		Attorney Docket Number	V637-02674 US
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